Lateral and norm al forces between patterned substrates induced by nem atic uctuations

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We consider a nem atic liquid crystal con ned by two parallel at substrates whose anchoring conditions vary periodically in one lateral direction. W ithin the Gaussian approximation, we study the elective forces between the patterned substrates induced by the thermal uctuations of the nem atic director. The shear force oscillates as function of the lateral shift between the patterns on the lower and the upper substrates. We compare the strength of this uctuation-induced lateral force with the lateral van der W aals force arising from chemically structured adsorbed m onolayers. The uctuation-induced force in norm all direction is either repulsive or attractive, depending on the m odel param eters.

PACS num bers: 61.30 D k, 61.30 H n

I. IN TRODUCTION

Liquid crystals are characterized by large therm al uctuations in their local orientational order arising from collective alignment of the long axis of their constituent molecules [1]. Due to such soft anisotropy, liquid crystals tend to respond easily to external forces. Con ning geometries such as thin Ims, on which most applications of liquid crystals are based, change the uctuation spectrum. This can cause not only structural changes [2, 3] but also leads to uctuation-induced effective forces between the substrates [4], also known as therm odynam ic Casim ir e ect. In correlated uids such as liquid crystals this Casim ir force exhibits a universal power-law decay as a function of the separation between the substrates [5]. However, this behavior is modi ed in the presence of other characteristic scales in the system [6, 7, 8]. In the case that the substrates are laterally m odulated, discrete lateralm odes of therm al uctuations are also excited. Under such conditions, in addition to the forces acting perpendicularly to the substrates, e ective lateral forces arise [9, 10] with potentially interesting technological applications. We study the in uence of anchoring conditions, which vary periodically in one lateral direction, on the uctuations of a uniform ly ordered nem atic liquid crystal. Obviously, the periodicity of the substrate pattern gives rise to an oscillatory behavior for the lateral force as a function of the lateral shift

between the substrates. For sm all inhom ogeneities the

lateral force is proportional to sin (2 =). (The analysis of nonperiodic patterns would provide an understanding of nem atic phases exposed to chem ically disordered substrates.) The present study actually extends our previous work [11] where we considered the case in which only one of two con ning substrates exhibits a chem ical pattern so that there are no lateral forces. Here, in addition to the uctuation-induced lateral forces, we calculate the lateral force between the patterned substrates across the vacuum , i.e., the background van der W aals force acting parallel to the substrates. This background force is generated by the necessary chem ical m odulations providing the laterally varying anchoring strengths.

In Sec. II our model and the theoretical form alism are specified. In Sec. IIIA the uctuation-induced lateral force is obtained. In Sec. IIIB we calculate the lateral van der W aals force between the patterned substrates. The results for the uctuation-induced norm all force are presented in Sec. IV and nally Sec. V summarizes our results.

II. SYSTEM AND FORMALISM

W e consider a nem atic liquid crystal con ned by two at but chem ically patterned substrates at a separation d. The patterns on the both substrates consist of the same periodic stripes of anchoring energies per area W_a and W_b along the x direction but shifted relative to each other by the length (see Fig. 1). The substrates are translationally invariant in the y direction. The stripes are considered to vary with respect to the strength of hom eotropic anchoring so that the mean orientation of the director n is spatially hom ogeneous but the therm al uctuations vary laterally giving rise to e ective lateral

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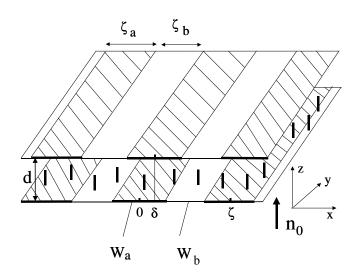


FIG. 1: The geometry of the nem atic cell with patterned substrates. The patterns on both substrates are the same but shifted relative to each other. The patterns consist of periodic stripes of anchoring energies per area W_a and W_b with the widths _a and _b, respectively. The wavelength of the periodicity is denoted as = a + b and the lateral shift between the origins of the patterns on the top and the bottom substrate is denoted by . Anchoring at both boundaries is hom eotropic everywhere so that the therm al average of the director eld n₀ = 2 is spatially hom ogeneous.

forces. Based on the bulk structuralFrank free energy [1] given by

$$F_{b}[n] = \frac{1}{2} \int_{V}^{Z} d^{3}x K_{1}(r + r^{2}) + K_{2}(n + r^{2}) + K_{3}(n + r^{2}) + K_{3}(n + r^{2}); \quad (1)$$

where V is the nem atic volume, K_1 , K_2 , and K_3 are the splay, the twist, and the bend elastic constants, respectively, the free energy of G aussian uctuations in the one-constant approximation reads

$$F_{b}[_{1};_{2}] = \frac{X^{2}}{\sum_{i=1}^{K} \frac{K}{2}} d^{3}x [r_{i}(x;z)]^{2}; \qquad (2)$$

where i, i = 1;2, is either of the two independent com – ponents of the uctuating part = n n_0 of the director n, K = K₁ = K₂ = K₃ is the elective elastic constant, and x = (x;y) are the lateral components of the C artesian coordinates r = (x;z).

To describe the interaction of the liquid crystal and the substrates, we employ the Rapini-Papoular surface free energy given by

$$F_{s}[n] = \frac{1}{2} \int_{s}^{2} d^{2}x W^{z=0}(x) (n \ 2)^{2}$$

$$\frac{1}{2} \int_{s}^{Z} d^{2}x W^{z=d}(x) (n \ 2)^{2} = F_{s}^{z=0} + F_{s}^{z=d} \qquad (3)$$

where W is the anchoring energy per area S and \hat{z} is the unit vector in z-direction. Here W $z^{z=0}(x) = W_{a}a(x) +$

 $W_{b}[l = a(x)]$ at the lower substrate located at z = 0 and $W_{z=d}(x) = W_{a}b(x) + W_{b}[l = b(x)]$ at the upper substrate located at z = d where

$$a(x) = {x^{i} \over k = 1} x k + {- 4 \over 4} k + {- 4 \over 4} x$$
 (4)

and

$$b(x) = a(x +)$$
 (5)

describe the stripe m odulations at the low er and the upper substrates, respectively, (x) is the H eaviside step function, and is the periodicity. The stripes have the same width $_{a} = _{b} = =2$ and are separated by sharp chem ical steps. The functions a(x) and b(x) equal one at the regions characterized by W_a and zero elsewhere at the low er and the upper substrates, respectively. Thus the surface free energy of the G aussian uctuations given by $F_{s}[_{1};_{2}] = F_{s}[_{1}] + F_{s}[_{2}]$ reads

$$F_{s}^{z=0}[] = \frac{1}{2}^{h} W_{a}^{Z} d^{2}x \quad (x;z=0)^{2}a(x) + W_{b} d^{2}x \quad (x;z=0)^{2}[1 a(x)]$$
(6)

at the lower substrate and

$$F_{s}^{z=d}[] = \frac{1}{2} \frac{h}{w} a_{a}^{z} d^{2}x \quad (x;z=d)^{2}b(x) + W_{b} d^{2}x \quad (x;z=d)^{2}[1 \quad b(x)]$$
(7)

at the upper substrate.

M inimization of total free energy $F = F_b[_1;_2] + F_s^{z=0}[_1;_2] + F_s^{z=d}[_1;_2]$ leads to two boundary conditions:

$$K (Q_z (x;z) + W_a (x;z)a(x) + W_b (x;z) [1 a(x)] = 0; z = 0; (8a)$$

$$K (\theta_z (x;z) + W_a (x;z)b(x) + W_b (x;z) [1 b(x)] = 0; z = d;$$
 (8b)

where is either $_1$ or $_2$.

A. Path integral technique

The norm alized [see, c.f., after Eq. (9)] partition function Z of the uctuating elds $_{i}$, i = 1;2, subject to the boundary conditions given by Eqs. (8 a) and (8b) can be calculated within the path integral approach (see Ref. [11] and references therein). The boundary conditions act as constraints which can be implemented by delta functions. They, in turn, can be written as integral representations by introducing two auxiliary elds localized at z = 0 and z = d, respectively [12, 13]. A fter perform ing the corresponding G aussian integrals over i, i = 1;2, the path integral reduces to a Gaussian functional integral over the auxiliary elds with a matrix kernelM, so that obtaining the result for Z reduces

to calculating (detM) $^{1=2}$. For the geom etry considered here, the m atrix M $\,$ is found to have the follow ing m atrix elem ents M $\,$; ; ; = 1;2:

$$M_{11} (x; x^{0}) = {nh + \frac{b - a}{a}} a(x) {1 + \frac{b - a}{a}} a(x^{0})^{i}$$

$$+ \frac{b(b - a)}{a} [a(x) - a(x^{0})] [a_{z} - \frac{2}{b} [a_{z}^{2}]^{O} G(x - x^{0}; z - z^{0})]_{z=z^{0}=0};$$

$$M_{12} (x; x^{0}) = {1 + \frac{b - a}{a}} [a(x^{0}) + b(x)] - 2 b [a_{z^{0}} - \frac{b(b - a)}{a}] [a(x^{0}) + b(x)] [a_{z^{0}}]_{z=d; z^{0}=0};$$

$$+ \frac{b - a}{a} - \frac{2}{a} (x^{0}) b(x) + \frac{2}{b} [a_{z^{0}}]^{O} G(x - x^{0}; z - z^{0})]_{z=d; z^{0}=0};$$

$$M_{21} (x; x^{0}) = {1 + \frac{b - a}{a}} [a(x) + b(x^{0})] - 2 b [a_{z} - \frac{b(b - a)}{a}] [a(x) + b(x^{0})] [a_{z}]$$

$$+ \frac{b - a}{a} - \frac{2}{a} (x) b(x^{0}) + \frac{2}{b} [a_{z}]^{O} G(x - x^{0}; z - z^{0})]_{z^{0}=d; z^{0}=0};$$

$$M_{22} (x; x^{0}) = {1 + \frac{b - a}{a}} b(x^{0}) + \frac{b - a}{a} b(x^{0}) + \frac{b - a}{a} b(x^{0})$$

$$+ \frac{b(b - a)}{a} [b(x^{0}) - b(x)] [a_{z} - \frac{2}{b} [a_{z}^{2}]^{O} G(x - x^{0}; z - z^{0})]_{z=z^{0}=d};$$

where $_{a(b)} = K = W_{a(b)}$ is the so-called extrapolation length and $G(r;r^0) = k_B T = (4 K jr r^0)$ is the two-point correlation function of the scalar eld i in the bulk with its statistical weight given by $Z_0^{-1} \exp f_{\frac{K}{2k_B T}} V_V d^3x_i(x;z)O^2_i(x;z)g$ where the normalizing factor Z_0 is the bulk partition function and $k_B T$ is the thermal energy.

In term s of the partition function Z , the free energy is given by F = $~k_{B} \mbox{ T } \ln Z$ = $(k_{B} \mbox{ T } = 2) \mbox{ hdet } M$. We note that normalizing Z by Z $_{0}$ amounts to subtracting the bulk free energy, so that the free energy F includes only the surface free energy and the nite-size contribution. The surface free energy depends neither on d nor on , so the uctuation-induced force F = $~\ell \mbox{ F }$ reads

$$F = \frac{k_{\rm B} T}{2} Tr (M^{-1} @M); \qquad (10)$$

where 0 is either 0 or 0_d corresponding to lateral or norm ald splacem ents giving rise to lateral or norm all forces, respectively.

B. Periodic m odulation

The matrix kernel M is a functional of the patterning function a(x) on the substrates and therefore calculation of the inverse of M is nontrivial. However, in system s with in-plane symmetries one may proceed by a lateral Fourier transformation with respect to the lateral coordinates x = (x;y). In Ref. [14], it is shown how the electrodynamic Casim ir force can be calculated for a periodically modulated substrate (see also Refs. [11, 15]). In this reference, the lateral periodicity is used to transform the matrix M to a block-diagonal form in Fourier space (p;q) in which M (p;q) = $d^2x d^2x^0M (x;x^0)e^{ip - x}e^{iq - x^0}$. Similarly, also here the matrix elements of the block M j = M _{j;k1} with M _{j;k1}(p_y;q_y) = 2 p_y + q_y B_{k1} $\frac{2 - j}{L}$;p_y, j = 1; ;N = L = , are given by

$$B_{kl} = \frac{2 j}{L}; p_y = N_{m=kl} = \frac{2 j}{L} + \frac{2 l}{L}; p_y$$
 (11)

for l;k 2 Z, where L is the lateral extension of the system in the x direction and the N $_{\rm m}$ are (2 $\,$ 2) m atrices providing the following decomposition of the matrix M :

$$M (p;q) = (2)^{2} (p_{y} + q_{y}) \qquad N_{m} (p_{x};p_{y}) \\ m = 1 \\ p_{x} + q_{x} + \frac{2 m}{2} : \qquad (12)$$

However, it is interesting to note that the matrix M(x;x') = M(x x;a(x);a(x')) can also be represented, using a more direct derivation than in Ref. [14], in a form in which M is diagonal [16]. In view of the discrete lateral periodicity along the x direction, it is suitable to

(9)

 $express x and x^{\circ} as$

$$x = n + s; \quad x = n^{\circ} + s^{\circ};$$
 (13)

with n;n[°] 2 Z and s, s[°] 2 [0;). Since a (x) is periodic with wavelength it follows that a (x) = a (s) and x $\dot{x} = (n n^{\circ}) + s$ s depends on n and n[°] only via the di erence n n[°]. This property and translational invariance along the y direction in ply the Fourier decom – position

$$M^{\circ}(p_{x};p_{y};s;s^{\circ}) = \begin{array}{ccc} x^{i} & Z & Z \\ & dy & dy^{\circ} \\ & & & \\ & & & \\ n;n^{\circ}= 1 \end{array}$$

$$M^{\circ}(n & n^{\circ};y & y^{\circ};s;s^{\circ})e^{ip_{x}(n - n^{\circ})}e^{ip_{y}(y - y^{\circ})} \quad (14)$$

where \hat{M} ($p_x; p_y; s; s'$) is diagonal. Furtherm ore with s, $s^2 \ge 0;$) one can form

$$C_{k1} (p_{x}; p_{y}) = ds ds^{\circ}$$

$$e^{2 iks=} \hat{M} (p_{x}; p_{y}; s; s^{\circ}) e^{2 ils^{\circ}} : (15)$$

As expected, the di erent representations of M in terms of the matrices C or B (C is the Fourier transform of \hat{M} and B is the Fourier transform of $e^{ip_{X}s} \hat{M} e^{ip_{X}s^{0}}$) do not change the nal result for the force [Eq. (10)] which is given by [14]

$$F = \frac{k_{\rm B} T S}{2^{2}} \frac{R_{1}}{{}_{0}} \frac{Z_{2}}{dp_{\rm y}} \frac{dp_{\rm x}}{{}_{0}} dp_{\rm x}$$

tr B¹ (p_x; p_y) (eB (p_x; p_y)) : (16)

Here tr denotes the partial trace with respect to the indices k; lofthe in nite-dimensional matrix B (or C) and we have taken into account the contribution of both uctuating components of the director eld.

In the following we continue with the block-diagonal form of the matrix kernel M since in this representation the patterning functions a_k and b_k are somehow simpler than their counterparts in the diagonal form of M. A coordingly, the matrices N_m [Eq. (12)] are given by

$$N_{m} = \begin{pmatrix} a^{a}(0) & a^{b}(d) \\ m^{a}(0) & m^{b}(d) \\ b^{a}(0) & m^{b}(0) \\ 0 & \frac{(1 - b^{p})^{2}}{2p} e^{pd} & \frac{z_{b}^{2}}{2p} & \frac{(1 - b^{p})^{2}}{2p} e^{pd} \\ h & \frac{(1 - b^{p})^{2}}{2p} e^{pd} & \frac{z_{b}^{2}}{2p} \\ h & \frac{(1 - b^{p})^{2}}{2p} e^{pd} & \frac{z_{b}^{2}}{2p} \\ h & \frac{(1 - b^{p})^{2}}{2p} e^{pd} & \frac{z_{b}^{2}}{p} \\ h & \frac{(1 - b^{p})^{2}}{2p} e^{pd} & \frac{z_{b}^{2}}{p} \\ h & \frac{b^{a}}{2} \\ h & \frac{b^{a}}{2} e^{pd} & \frac{a^{b}}{p} e^{pd} \\ h & \frac{a_{0}}{2} e^{\frac{z_{b}^{2}}{p}} e^{pd} & \frac{z_{b}^{2}}{p} e^{pd} \\ h & \frac{b^{a}}{p} e^{pd} \\ h & \frac{a_{0}}{2} e^{\frac{z_{b}^{2}}{p}} e^{pd} \\ h & \frac{b^{a}}{p} e^{pd} \\ h & \frac{a_{0}}{2} e^{\frac{z_{b}^{2}}{p}} e^{pd} \\ h & \frac{a_{0}}{2} e^{\frac{z_{b}^{2}}{p}} e^{pd} \\ h & \frac{a_{0}}{2} e^{$$

form even, and

 \cap

$$N_{m} = \frac{b}{2} a \frac{a}{b_{m}} \frac{B}{p} b e^{pd} + a_{m} \frac{z_{b}}{p_{m}} b e^{pmd} + a_{m} \frac{z_{b}}{p_{m}} b e^{pmd} \frac{1}{b_{m}} \frac{z_{a}}{b_{m}} b e^{pmd} \frac{1}{b_{m}} \frac{z_{a}}{b_{m}} b e^{pmd} \frac{1}{b_{m}} \frac{1}{$$

for m odd, with $z_{a(b)} = q \frac{1 + \frac{b - a}{a} a_0 (b_0), z_{a(b)}^c}{(p_x + 2 m =)^2 + p_y^2} = 1 + \frac{b - a}{2 a} a_0 (b_0), p_m = \frac{q}{(p_x + 2 m =)^2 + p_y^2}, p = p_{m=0}, a_0 = b_0 = 1=2, a_{m=odd} = (1)^{(jm \ j \ 1)=2} = (jm \ j), b_{m=odd} = e^{2 im} = a_m$, and

$$ab_{m}^{ab}(d) = \frac{b_{a}}{a} \frac{2 X^{d}}{a} \frac{0}{a_{k m} b_{k}} \frac{e^{p_{k} d}}{2p_{k}};$$
(19)

where the prime at the sum mation sign indicates that in the sum the term swith even k are excluded.

III. LATERAL FORCES

A. Fluctuation-induced shear forces

In the limit d we nd that the contributions from the elements B_{k1} [Eqs. (11) and (12)] to the force decrease rapidly with increasing absolute values of k; l, so that the expression for the force [Eq. (16)] converges already at small orders of M with k; l = M; ;M. Taking into account only the elements B_{k1} [Eq. (11)] for k; l = 1;0; l, the asymptotic behavior of the uctuation-induced lateral force $F_{lat} = @F$ in the limit $j_b a \neq a$ 1 is given by

$$\frac{F_{lat}(d)}{k_{B}TS} = \frac{8(b_{a})^{2}}{3\frac{2}{a}}e^{2d} = \sin \frac{2}{a}$$

$$f(d=;b=) + O \frac{b_{a}}{a}^{3}$$
(20)

with the dimensionless function

$$f(u;v) = \frac{1}{(1+2v)^2} \int_{0}^{2^{-1}1} dx e^{ux}$$

$$\frac{1 \frac{1+2v(1vx)x+(\frac{x}{2})^2(1+4v)}{(1vx)^2}e^{2ux}}{1 \frac{\frac{1+vx}{1vx}}{2}e^{2ux}}:$$
(21)

The lateral force oscillates as function of the ecting the underlying lateral periodic pattern and its magnitude decays exponentially as function of d= , because f (1 ;v) < 1 .

For arbitrary values of d, we evaluate the force in Eq. (16) num erically. A lthough the matrix B [Eq. (11)] is in nite-dimensional, the value of the force saturates at some nite values for k; l. Our num erical results for the uctuation-induced lateral force as function of the for arbitrary strength of the contrast b shift are shown in Fig. 2. The lateral force acts against the increase of the lateral displacement in the interval [0; =2) by being a restoring force and acts favorably with the increase of in the interval (=2;] by being a pulling force. Therefore the force is antisymmetric with respect to = 0.5. Upon approaching the maxim um misalignment, i.e., = = 0.5, the restoring force vanishes. This implies that the interaction free energy $\int_{0}^{\infty} F_{lat}() d^{\circ} has its maximum at = = 0.5$ $V_{lat}() =$ where the opposing parts of the substrates face each other and attains its minimum at = 0. The force is maximal at = 0.25 and 0.75 where V_{at} exhibits its strongest dependence on (Fig. 3). In Fig. 4 we show the decay of F_{lat} as function of d. A sym ptotically, $F_{lat} = (k_B T S = {}^3)$ vanishes as $0.003 e^{2} d^{=} = (d^{=})$ for $a^{=} = 4$, $b^{=} = 8$, and = = 0.25.

We note that due to the assumption $_{a} = _{b}$ interchanging $_{a}$ and $_{b}$ leaves the system unchanged Fig.1]. Thus the force must be identical for $_{a}$ \$ $_{b}$. While in Eqs. (20) and (21) this symmetry is explicitly valid up to the second order in ($_{b}$ _ a), the numerical results respect this symmetry fully. This provides a very useful check of the numerical calculations.

B. Lateral van der W aals force

Endowing the substrates with the envisaged stripe pattems requires corresponding chemical patterns which in

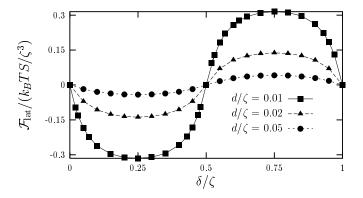


FIG. 2: The uctuation-induced lateral force F $_{lat}$ in units of k_B T S = ³ between two periodically patterned substrates at distance d as function of the shift in units of the periodicity

for d= = 0.01; 0.02, and 0.05 (see Fig. 1). The anchoring on the stripes in terms of the extrapolation lengths is taken to be $_{a}$ = = 4 and $_{b}$ = = 8. F_{lat} is antisymmetric around = = 0.5. There is no restoring force if the m isalignment is maximal, i.e., at = = 0.5. F_{lat} < 0 m eans that the plates are pulled back towards the preferred alignment at = 0; for F > 0 the plates are pulled forward towards preferred alignment at = .

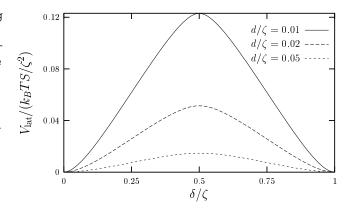


FIG. 3: The elective lateral potential $V_{lat}() = \frac{1}{R}$ F $_{lat}()^{0}$ in units of k_{B} T S= 2 between two periodically patterned substrates at distance d as function of the shift in units of the periodicity for d= = 0.02; 0.03, and 0.05 and $_{a}$ = 4, $_{b}$ = 8. For all values of d= the in ection points of the potential are at = 0.25 and 0.75.

tum involve at least two di erent species providing the chem ical contrast. These species do not only interact (di erently) with the nem atic liquid crystal in the vicinity of the substrate, giving rise to two di erent extrapolation lengths _a and _b, but also interact across the liquid crystal with each other via dispersion forces. The later interaction provides a lateral force as well which adds to the uctuation-induced lateral force. Note that such a

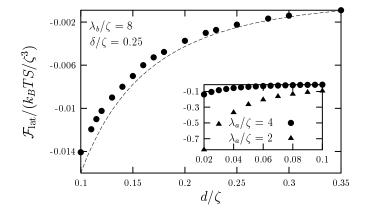


FIG. 4: The uctuation-induced lateral force F_{lat} in units of $k_B T S = {}^3$ between two periodically patterned substrates as function of the lm thickness d in units of the periodicity . The anchoring on the stripes in terms of the extrapolation lengths is taken to be $_a = = 4$, $_b = = 8$, and the lateral shift between the patterns is = = 0.25. A sym ptotically, $F_{lat} = (k_B T S = {}^3)$ for = = 0.25 vanishes as $0.003 e^{2} d^{=} = (d =)$ (dashed line). The variation of F_{lat} for sm all values of d = is shown in the inset for $_a = = 4$ (circles) and $_a = = 2$ (triangles). The other system parameters remain the same. As expected the absolute value of the am plitude of the lateral force increases upon increasing the contrast j b _ a j.

lateral force due to direct interactions is the same if the two patterned substrates are separated by vacuum or by a nem atic liquid crystal, as long as the mean nem atic order is not a ected by the stripe patterns.

In order to estim ate these direct interactions between the patterned substrates, we consider each substrate to be covered by a monolayer whose chemical composition varies periodically, alternating between A - and B particles. We neglect non-additivity aspects of the dispersion forces and consider pairwise interactions between the patterned monolayers at z = 0 and z = d. Since we consider d to be large compared with the diameters of the A and B particles, we can disregard that particles form ing the monolayers occupy discrete lattice sites. As pair potentials between the two species we take Lennard-Jones potentials

$$u_{ij}(\mathbf{r}) = 4_{ij} \frac{ij}{\mathbf{r}} \frac{12}{\mathbf{r}} \frac{ij}{\mathbf{r}} \mathbf{j}^{6i}; i; j = A; B$$
 (22)

where A (B)-particles give rise to the extrapolation length $_{a(b)}$. Since in the present context d $_{ij}$, for the lateral force only the attractive part of the pair potentials m at-

ters. This leads to the following expression for the van der W aals potential energy between the two monolayers:

$$V_{lat}^{vdW} () = \int_{S}^{Z} d^{2}x_{1} \int_{S}^{Z} d^{2}x_{2} \frac{E(x_{1}; x_{2};)}{[d^{2} + (x_{1} - x_{2})^{2}]^{3}}$$
(23)
with

$$E (x_{1}; x_{2};) = E_{AA} a (x_{1}) b (x_{2};) + E_{BA} a (x_{1}) 2a (x_{1}) b (x_{2};) + b (x_{2};) + E_{BB} [1 a (x_{1})] [1 b (x_{2};)]$$
(24)

and

$$E_{ij} = 4_{ij} {}^{6}_{ij i j}$$
 (25)

where $_{A(B)}$ is the areal number density of A (B)particles in the monolayer forming the stripe $_{a(b)}$. Carrying out the integration over y_1 and y_2 in Eq. (23), one obtains

where L is the lateral extension of the system both in the x and y directions. From this the lateral van der W aals force $F_{lat}^{vdW} = 0 V_{lat}^{vdW}$ () can be calculated:

$$\frac{F_{lat}^{vdW}}{S} = \frac{E}{5} f^{vdW} \quad (=;d=) \quad (27)$$

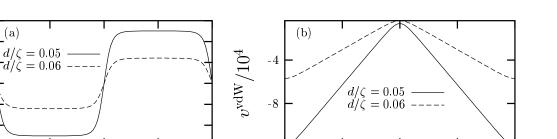
with the scaling function

$$f^{vdW} (=;d=) = \frac{15}{8} X^{1} Z_{n+1=2+} dX_{1}$$
$$dX_{1} dX_{2} \frac{X_{2} X_{1}}{[(d=)^{2} + (X_{2} X_{1})^{2}]^{7=2}} (28)$$

where $E = E_{AA}$ $2E_{AB} + E_{BB}$. The force and the potential as function of = are shown in Fig. 5. The comparison between Figs. 2 and 5 (a) reveals that the lateral van der W aals force is practically constant over a wide range of shift values and varies steeply around the positions of maximum and minimum misalignment while the uctuation-induced force varies more sm oothly across all shift values. Apart from that, the qualitative features are the same for both forces.

In order to estimate the lateral van der W aals force

we assume that the particles are closely packed within



0

0.25

0.5

 δ/ζ

0.75

1

FIG. 5: (a) The dimensionless scaling function f^{vdW} Eqs. (27) and (28)] of the lateral force induced by direct van der W aals interactions between the chem ically patterned m on layers covering the two substrates at distance d as function of the shift in units of the periodicity of the pattern for d= = 0.05 and 0.06. (b) Corresponding lateral potential V_{at}^{dW} () = $\frac{E S}{4} v_{lat}^{vdW} [E q: (26)]:$

1

the monolayer [17], so that the areal number density is $_{A(B)} = \frac{P}{3} = (6R^2) \qquad 2[_{AA(BB)}]^2 = \frac{P}{3}$ where R = $_{AA}$ =2 ($_{BB}$ =2) is the radius of the A (B) particles form ing a triangular lattice. A coording to Table I in Ref. [18] typical values are $_{ij}$ = k_B 300 K and $_{ij}$ 0.5 nm . For = 200 nm one has $E_{ij} = 5$ 1:5 $10^5 \text{ pN} = (\text{ m})^2$. According to Fig. 5 (a) for d = 0.05 this implies F vdW lat;ij $3 \text{ pN S}=(\text{ m})^2$ for the contribution / E_{ij} to the actual lateral van der W aals force F $_{\rm lat}^{\rm vdW}$ proportional to $E = E_{AA}$ $2E_{AB} + E_{BB}$. Thus for a suitably chosen constant E, without com prom ising the goal of achieving a = b=2 (as used in our calculations), the lateral van der W aals force can be quite sm aller than 3 pN per area $S = (m)^2$:

3

1

-1 -2 -3

0

 $f^{\rm vdW}/10^5$

(a)2

-d 0

0.25

0.5

 δ/ζ

0.75

From Fig. 2 one nds, for the same system param and d considered above and at room tempereters ature, for the uctuation-induced lateral force F_{lat} $0.02 \text{ pN S}=(\text{ m})^2$. Thus the background lateral van der W aals force tends to be stronger than the nem atic uctuation induced force. However, for a suitably chosen chem ical contrast of the particles form ing the chem ical stripes, it appears to be possible to determ ine the uctuation-induced lateral force by m easuring the shear force once with and once without the nem atic liquid between the patterned substrates. The ratio of the two forces for d = 0.05, a = 4, b = 8, and E = 51:5 10^5 pN=(m)² as function of is shown in Fig. 6. It appears that the uctuationinduced lateral force becom es more prom inent around = = 0:25;0:75. From Figs. 2 and 5 (a) one notices that both F $_{\rm lat} = S$ and F $_{\rm lat}^{\rm vdW} = S$ vanish linearly at = = 0;0:5;1:0 [as (0:084 + 0:168 =) pN = (m²) and (33:5+66 =) pN = (m^{2}) at = = 0:5, respectively, for d= = 0.05, $E = {}^{5} = 1.5$ 10^{5} pN = (m)², = 200 nm, and $k_B T = 4$ 10²¹ J] and since the slope of F_{lat}^{vdW} is much larger than the corresponding slope of F $_{\rm lat}$, the ratio $F_{lat} = F_{lat}^{vdW}$ at = = 0;0:5;1:0 is sm all. From Fig. 6 one should not draw the conclusion that the lateral uctuation induced force is at most half a percent of the cor-

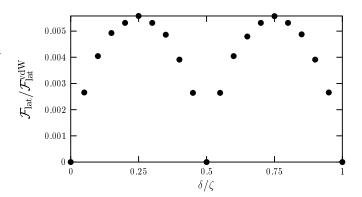


FIG.6: The ratio of the uctuation-induced lateral force F $_{\rm lat}$ and the lateral van der W aals force F $_{\rm lat}^{\rm vdW}$ as function of the shift in units of the periodicity for d = 0.05, a = 4, $_{b}$ = = 8, E = ⁵ 1:5 10 ⁵ pN = (m)², and at T = 290 K. F_{lat} is more prom inent around = = 0.25 and 0.75.

responding lateral van der W aals background force. This ratio is inversely proportional to $E = E_{AA} + E_{BB}$. Figure 6 corresponds to a param eter choice for which E is estim ated by an individual E ij and not by the actual contrast expressed by E, which vanishes for $A = B \cdot A c$ cordingly, for suitable choices of A and B, E can be signi cantly sm aller than the E_{ij} used in Fig. 6 which then leads to a signi cantly larger ratio.

IV. FLUCTUATION-INDUCED NORMAL FORCE

The e ect of a periodic anchoring at one substrate, with the second substrate being hom ogeneous, on the uctuation-induced norm alforce was studied in Ref. [11]. It turned out that for the description of the norm al force the single patterned substrate can be replaced by a uni-

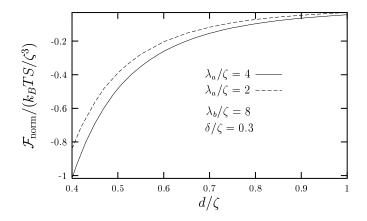


FIG.7: The uctuation-induced norm all force F_{norm} in units of k_B T S = ³ between two periodically patterned substrates as function of the lm thickness d in units of the periodicity . The anchoring on the stripes in terms of the extrapolation lengths is taken to be $_{b}$ = 8 and $_{a}$ = 4 (full line), 2 (dashed line). For d < $_{a}$; $_{b}$ as shown here the anchoring is weak but nite [5] at both substrates and the force is attractive. As expected the absolute value of the am plitude of the force decreases upon decreasing the extrapolation length. The force depends very weakly on the shift . Here = is set to 0:3.

form substrate with an e ective anchoring strength, i.e., the force is given by the force found between two uniform substrates characterized by their e ective anchoring. Depending on the model parameters, the norm alforce is either repulsive or attractive { corresponding to an e ective sim ilar-dissim ilaroran e ective sim ilar-sim ilarboundary condition, respectively. In the present case of two pattemed substrates, we have calculated the norm al force num erically [Eq. (16)]. Figure 7 shows the dependence of the norm alforce F_{norm} on d. For d < a; b as shown here, the force is attractive and decays monotonically as function of d. In this regime, the anchoring is weak at both substrates so that the e ect of the periodicity is not visible. We note that in this case the uctuationinduced norm al force [Fig. 7] is about 1000 (100) times larger than the uctuation-induced lateral force [Fig. 4] for a = 4 (2). Figure 8, how ever, show s the behavior ofF_{norm} as function of in the regime of strong but nite anchoring d > a; b. In this case the norm all force is oscillatory and attractive, and its magnitude is com parable with the uctuation-induced lateral force [Fig. 9].

V. SUMMARY AND CONCLUSION

W e have calculated the uctuation-induced forces acting on two substrates chem ically modulated with period

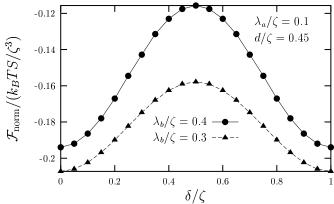


FIG.8: The uctuation-induced norm al force F_{norm} in units of $k_B T S = {}^3$ between two periodically patterned substrates at distance d= = 0.45 as function of the shift in units of the periodicity . The anchoring on the stripes in term softhe extrapolation lengths is taken to be $_a = = 0.1$ and $_b = = 0.3$ (triangles), 0.4 (circles). For d > $_a$; $_b$ as shown here the anchoring is strong but nite at both substrates and the force is attractive. As expected the absolute value of the amplitude of the force oscillates as function of the shift and for complete m isalignment, i.e., = = 0.5 the attraction is weakest.

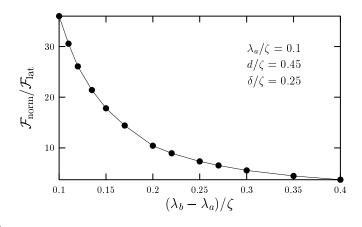


FIG.9: Fluctuation-induced norm all force F_{norm} divided by uctuation-induced lateral force F_{lat} as function of the contrast $_{\rm b}$ a in units of the periodicity for $_{\rm a}$ = 0.1, d= 0.45, corresponding to strong but nite anchoring, and = 0.25. F_{norm} and F_{lat} are of comparable size.

and con ning a nematic lm of thickness d (Fig. 1). The substrates are characterized by hom eotropic anchoring with alternating extrapolation lengths $_{a}$ and $_{b}$. We have studied the shear force as function of the lateral shift between the patterns on the substrates and of their separation d. For j_{b} $_{a}j$ $_{a}$ and d, the lateral force sinusoidally oscillates as a function of

= and decays exponentially with d= $\mathbb{E}q$. (20) and Fig. 4]. For stronger contrasts, the lateral force and its corresponding potential have been evaluated num erically \mathbb{F} igs. 2 and 3]. It turns out that for a suitably chosen chem ical contrast the uctuation-induced lateral force is com parable \mathbb{F} ig. 6] with the background lateral van der W aals force between the corresponding monolayers on the top and bottom substrates form ing the chem icalheterogeneity \mathbb{F} ig. 5]. In order to com plete the picture of the forces in the presence of the patterned substrates we have also calculated num erically the uctuation-induced norm al forces \mathbb{F} igs. 7 and 8] and found them to be com parable with the uctuation-induced lateral force in the case of strong anchoring \mathbb{F} ig. 9].

P atterning at small length scales gives rise to rich interfacial phenomena. Surface modulations open the possibility of controlling the morphology of wetting lm s and generate structural phase transitions which are central to the behavior of structural forces induced by distortions of the liquid crystal order parameter. In such cases, in addition to the uctuation-induced forces, the substrates are subject to liquid-crystalline elastic forces [3]. Such elastic forces scale with K [Eq. (2)] and are for larged larger than the uctuation-induced forces which scale with $k_B T$. Since for small d the elastic forces scale as d^{0.5} [2] but

the uctuation-induced force as d^3 [5], the latter can, how ever, even dom inate for smalld. The mean eld director contributions are completely eliminated for such m odelparam eters and boundary conditions for which the director structure is uniform. In Ref. [19] it has been dem onstrated that this uniform ity can indeed occur for suitable com binations of model parameters, even in cases of competing planar and hom eotropic anchoring conditions, which have not been considered here. Capillary forces due to capillary condensation and the form ation of bridge phases [20, 21, 22] are other sources for the structural forces in the vicinity of the new atic-isotropic phase transition. If the uid is con ned to very narrow slits, patterning m ay give rise to capillary bridges of different liquid crystalline order. Under such conditions, it would be interesting to study the stress under the shear strains by shifting the lateral substrate structures out of phase [23] which m ight give rise to rather strong lateral forces.

Lateral forces can technologically be used to align the parallel substrate structures. For instance, for those ranges of the model parameters for which the liquid crystalline lateral forces are signi cant, the liquid crystal can be led into the slit pore to align the substrate structure and then be rem oved.

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